

REMARKS

Applicant acknowledges allowance of claims 10-16.

Claim 1 has been amended to recite the limitation that the dissolution rate of the photoresist composition in aqueous base is less than about 1.3 $\times 10^{-4}$ $\mu\text{m/sec}$.

Claim 9 has been cancelled.

Rejection under 35 USC §103

Claims 1 and 6-8 are rejected under 35 USC §103(a) as being unpatentable over Kihara (5,332,648) in view of Wargo (5,426,222).

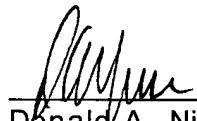
The allowable subject matter of Claim 9 having been incorporated into base Claim 1, Claim 1 and claims 2-8 dependent therefrom should now be allowable. Applicant requests reconsideration and allowance of claims 1-8.

CONCLUSION

The rejection of claims 1 and 6-8 under 35 USC §103(a) having been overcome, Applicants respectfully request reconsideration and withdrawal of the rejection, and that a timely Notice of Allowance be issued in this case.

Respectfully submitted,

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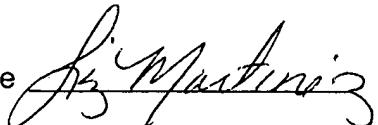


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Application No: 10/000,429

For Applicant: Dentinger